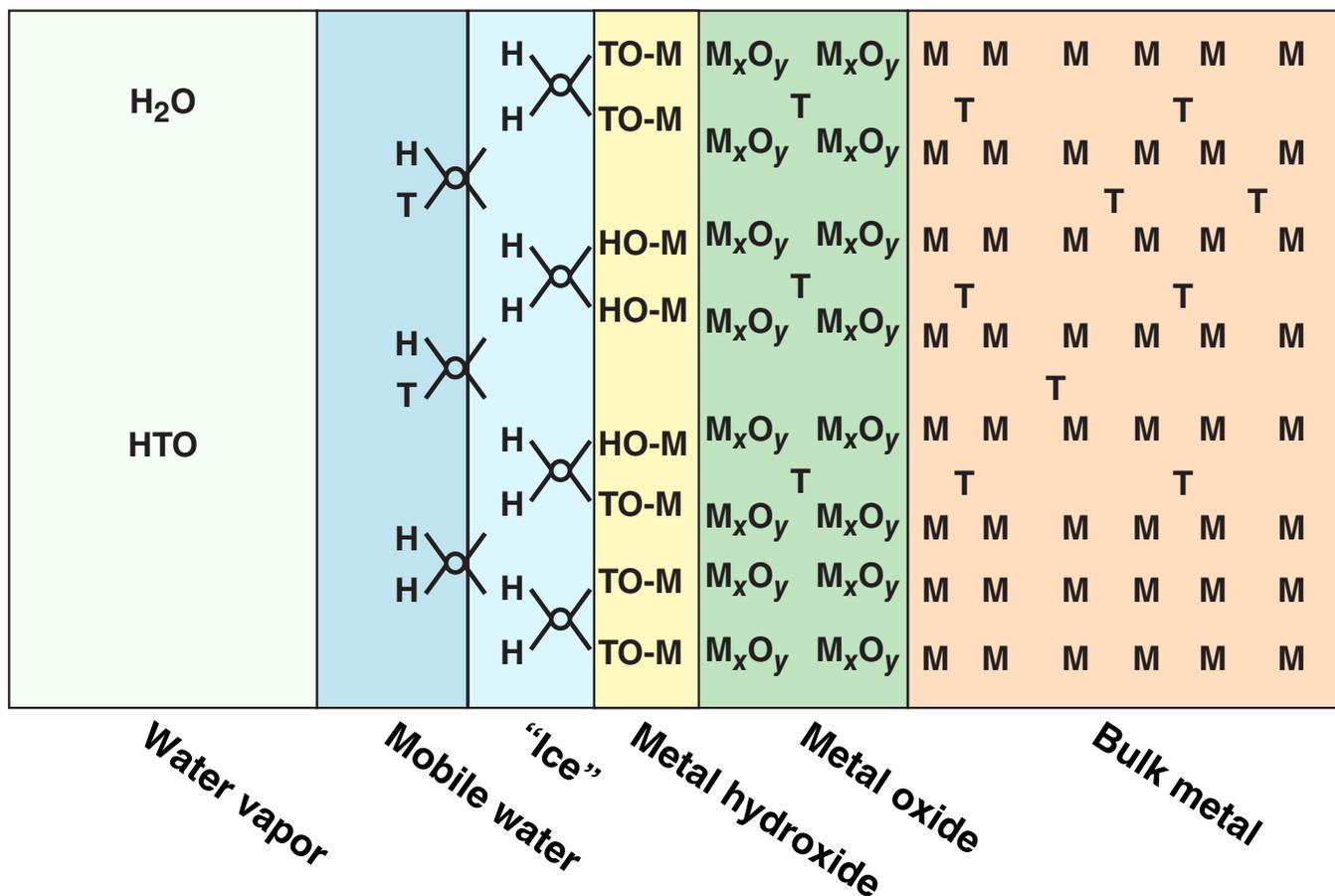


# Modeling Tritium on Metal Surfaces



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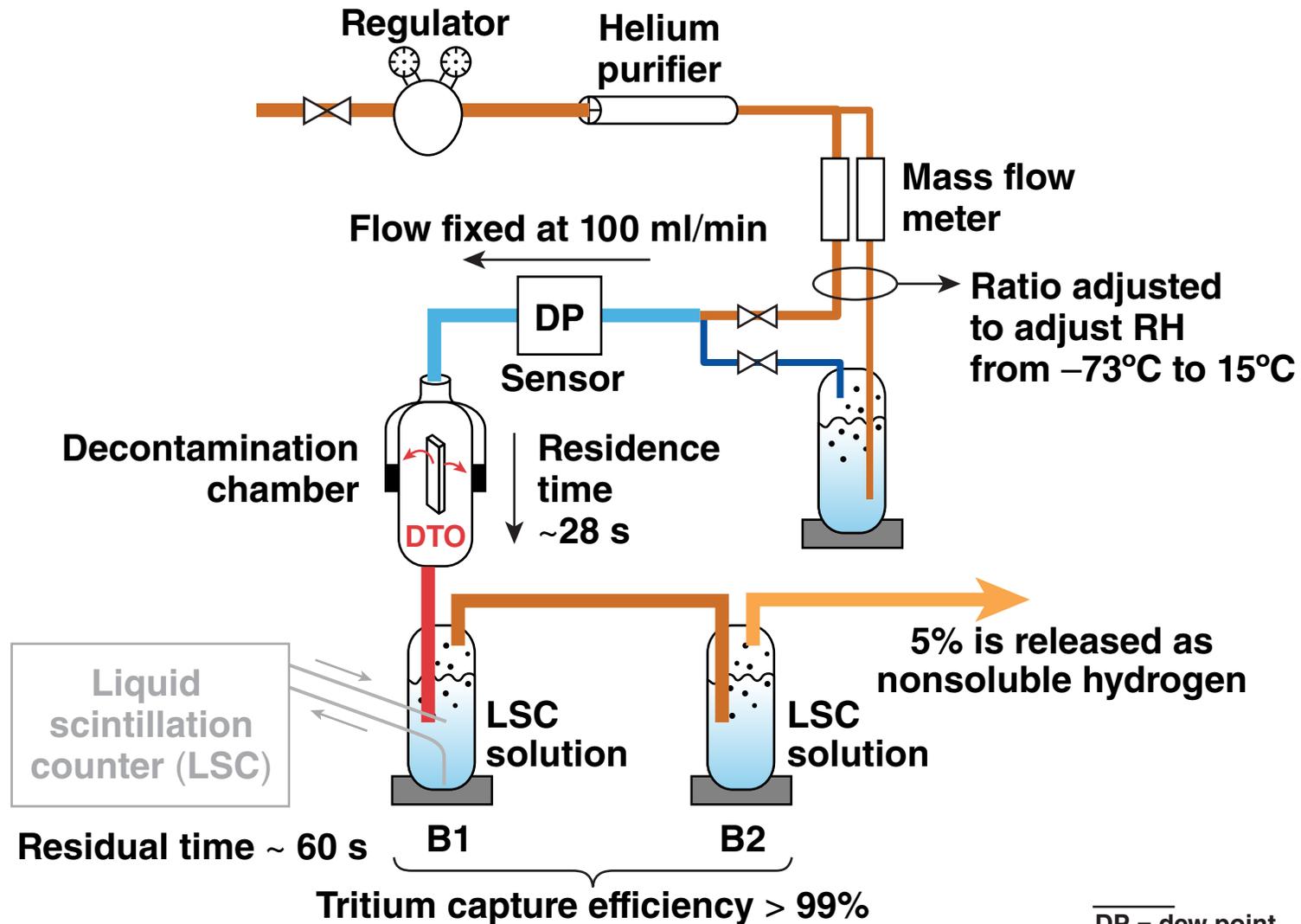
# Summary/conclusions

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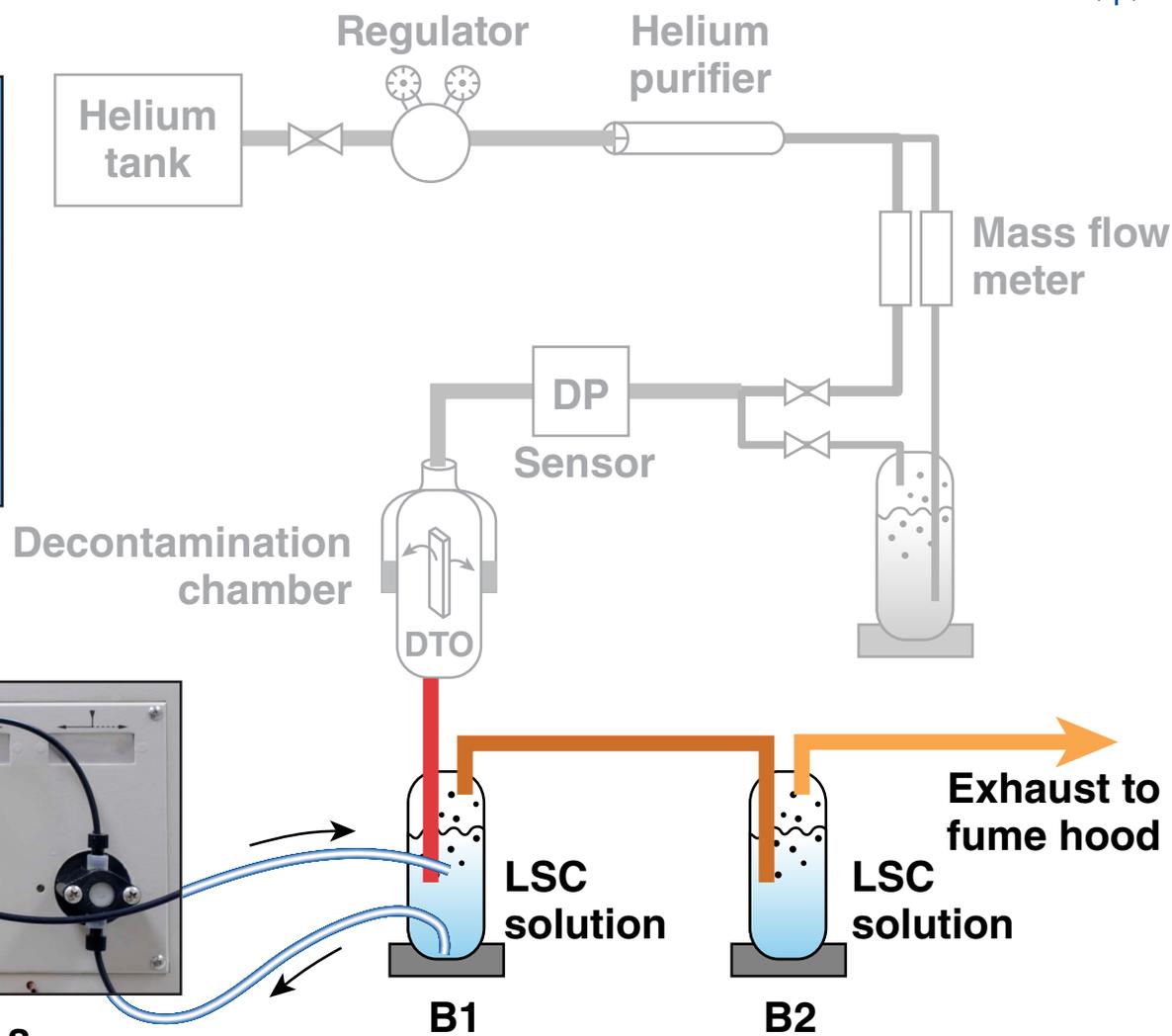
- **Two techniques have been used to study tritium in metals:**
  - **Linear thermal desorption**
  - **Pulsed RF Tonks-Langmuir plasmas**
  
- **Tritium concentrates in the water layers covering metal surfaces**
  
- **Surface water layers pump tritium from the bulk**
  
- **Regrowth of surface activity is**
  - **rapid and**
  - **Controlled by diffusion from the bulk metal**

# DTO is transferred from contaminated samples to the detection system using humid carrier streams



DP = dew point  
RH = relative humidity

# The liquid scintillation counter measures the activity in the first wash bottle in real time

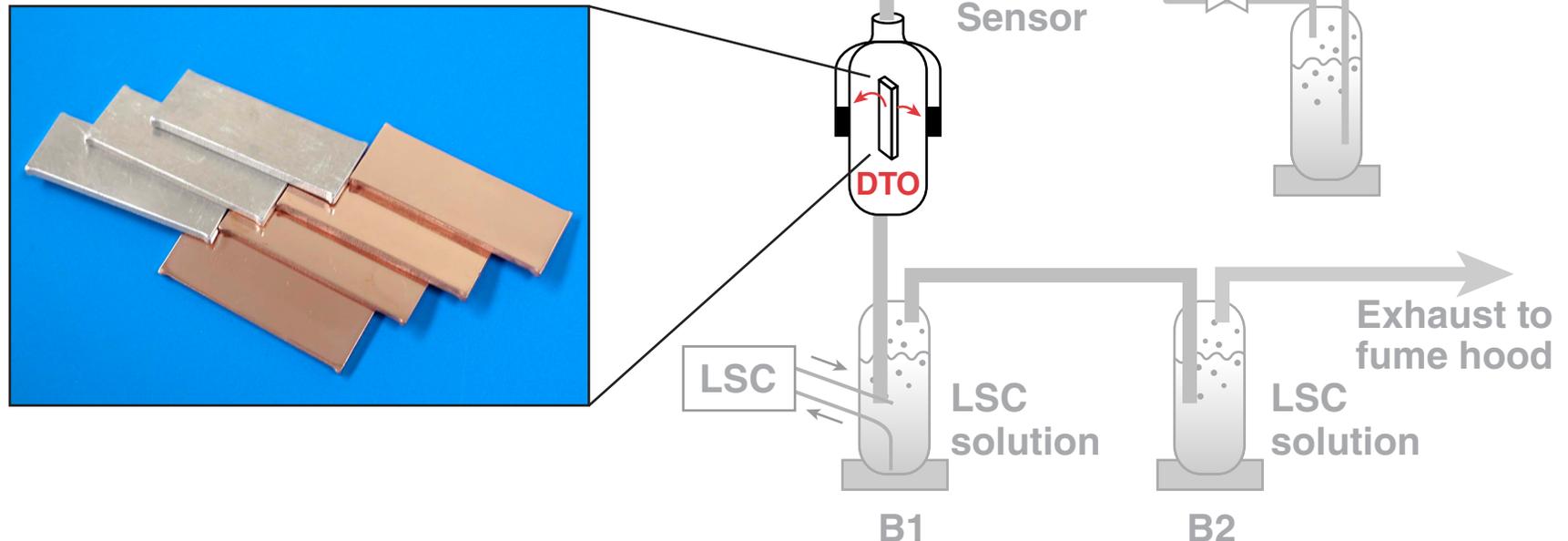


Residence time ~60 s

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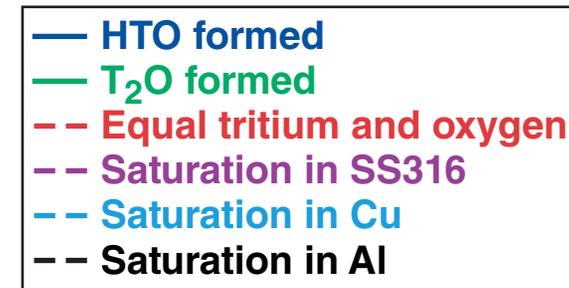
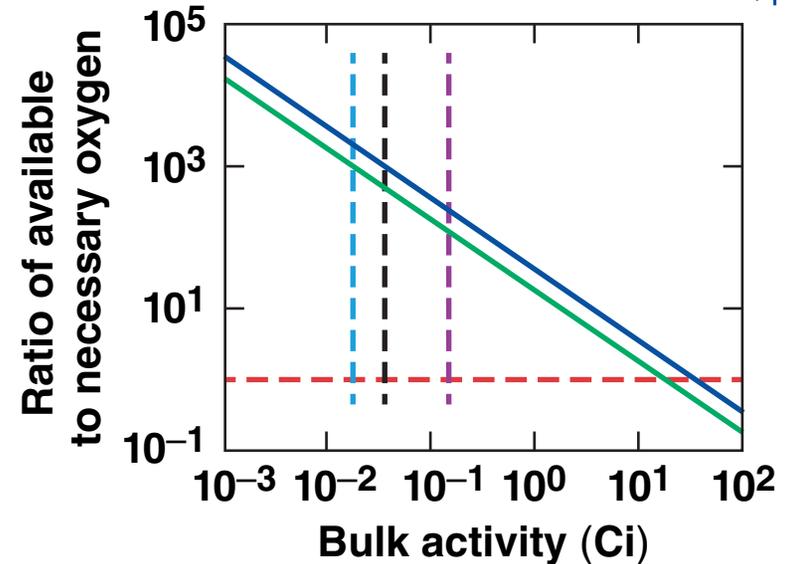
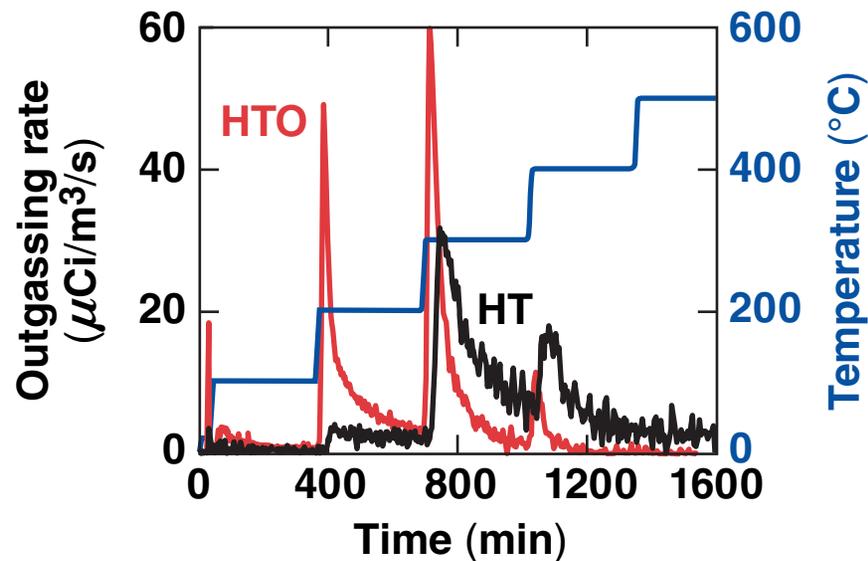
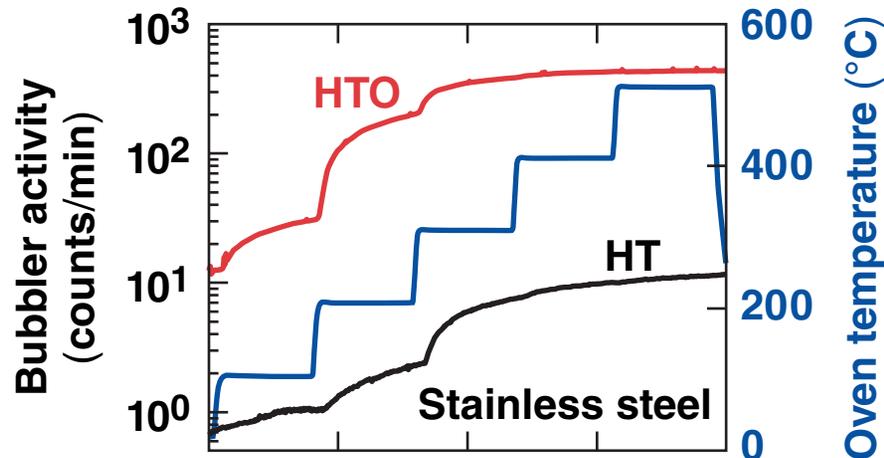
# The samples are exposed to DT gas and stored in dry helium at 1 atm and room temperature (RT)

- **Samples**  
5 × 1.8 × 0.3 cm
- **Stainless steel**  
exposed to 690 Torr DT  
for 23 h at RT
- **Cu** exposed to 729 Torr  
DT for 96 h at RT



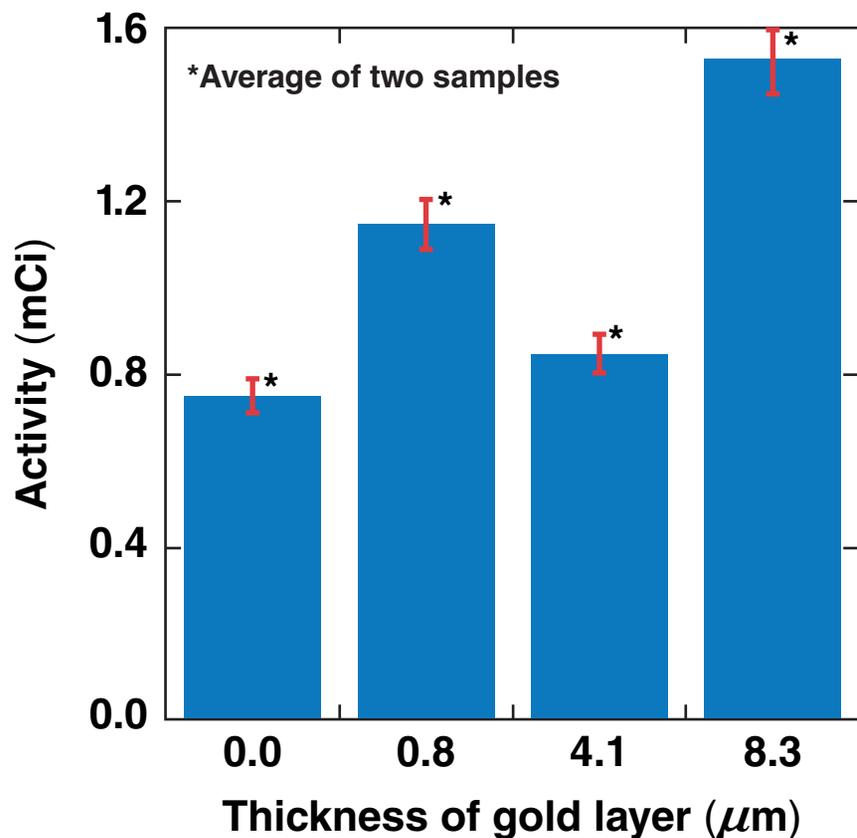
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# Linear thermal desorption provides a good measure of the total tritium absorbed in the metal

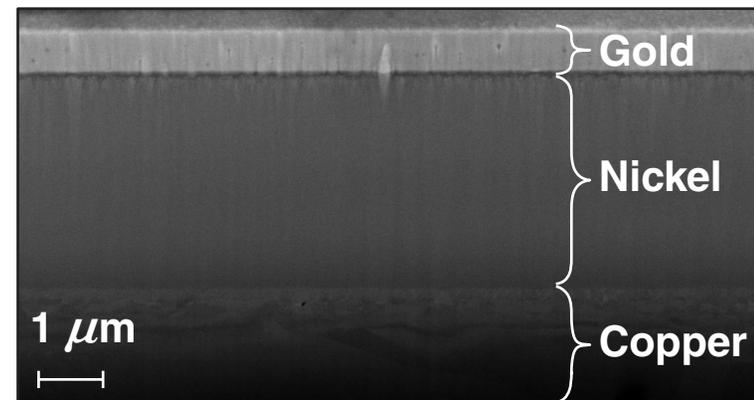


- Tritium release from metals is dominated by HTO under most typical exposure conditions

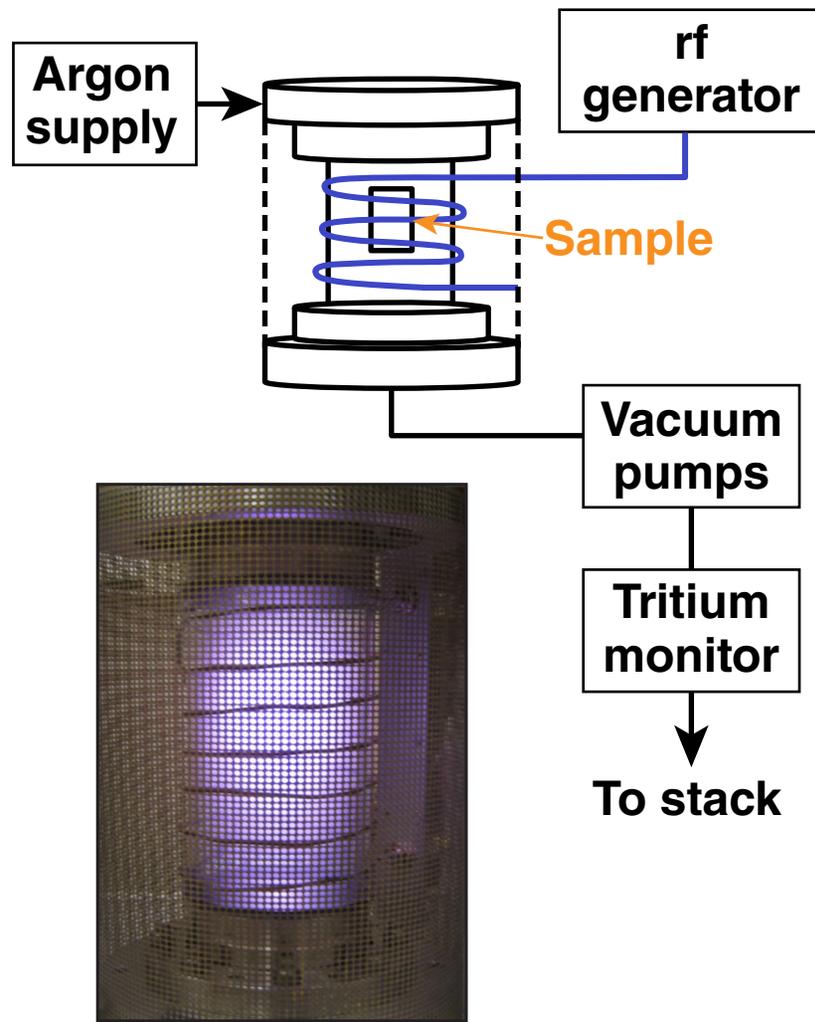
# The effectiveness of electrolytic deposition of gold layers may not lower tritium inventories in metals



- An increase in the total tritium inventory at low gold layer thicknesses implies asymmetric permeation
- Increased inventory at higher gold layer thicknesses implies that the solubility of gold exceeds stainless steel

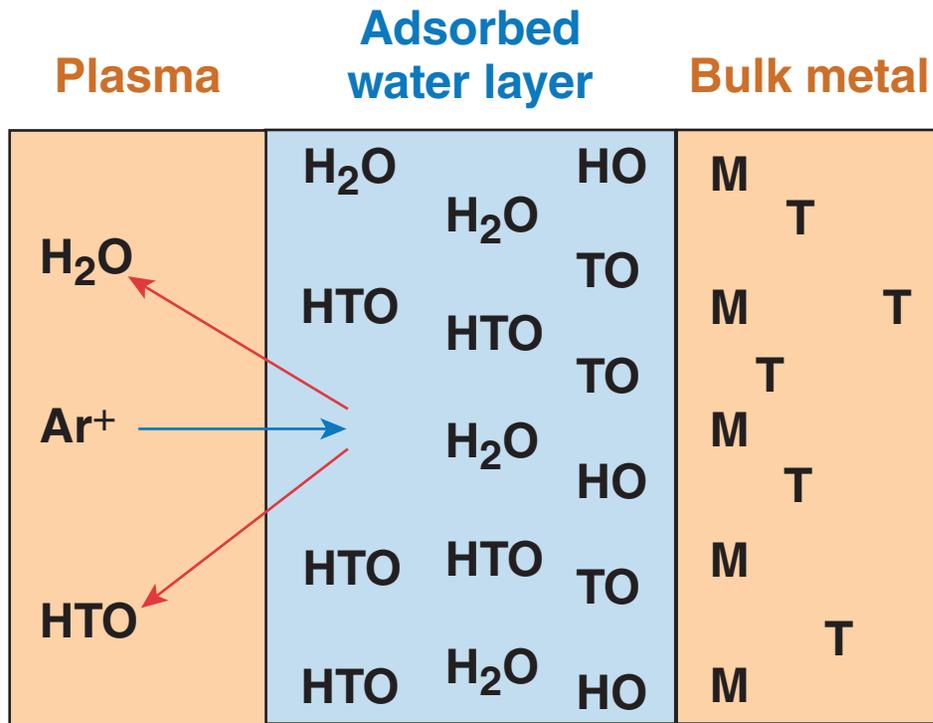


# Radio-frequency-generated argon plasma was used to desorb tritium from metals into a flowing gas stream



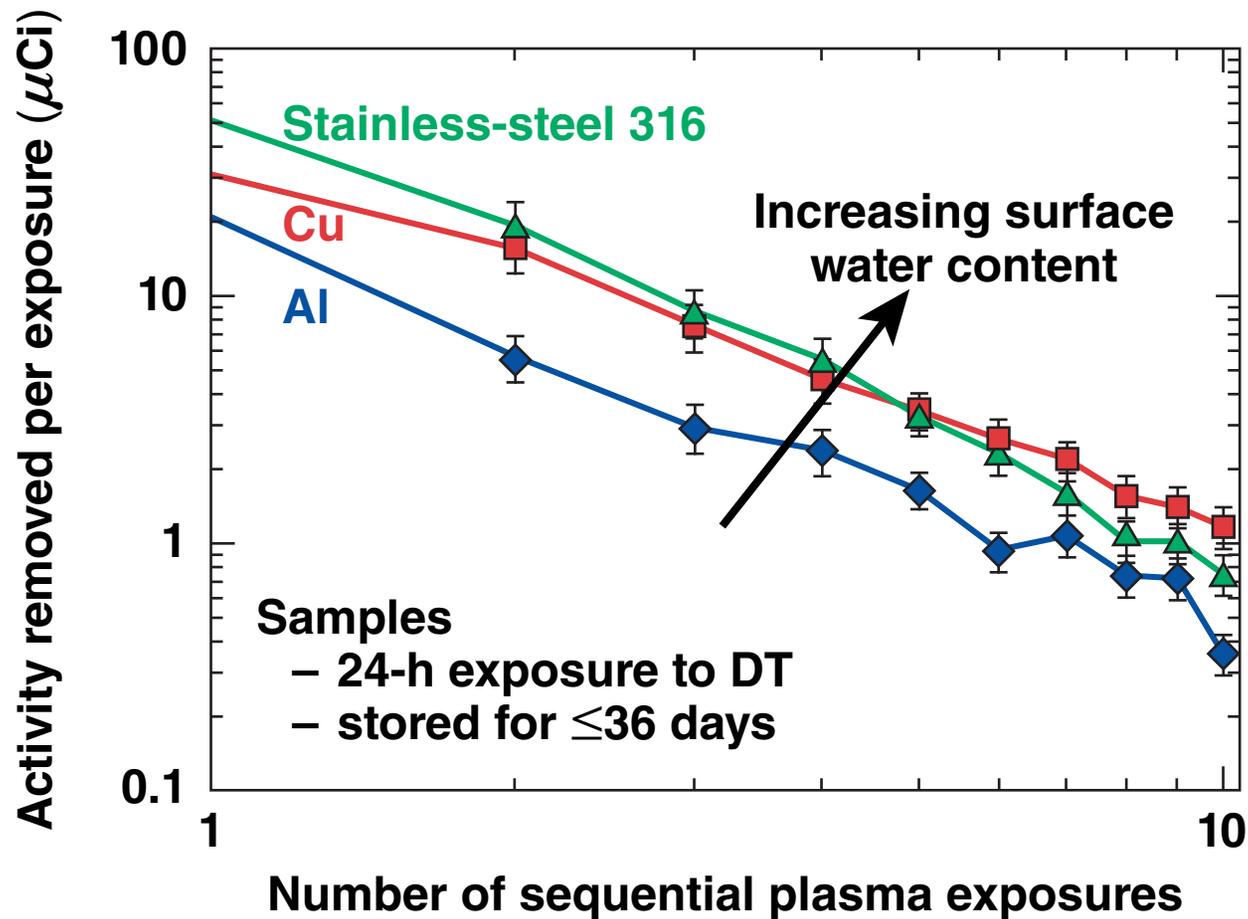
- A plasma was ignited in argon by passing a 13.56-MHz ac current through a copper coil
- The sample floated at the plasma potential
  - ionic flux = electron flux
- Tritium released from the sample was purged into a downstream in-line tritium monitor
- Base pressure  $\approx 10^{-4}$  Torr
  - trace water in the vacuum system redeposits on the metal surface within 15 s

# Water was removed from the sample surface using a series of 2-s plasma bursts



- Metal surface comprises
  - hydroxyl layer
  - proton bonded “ice” layer
  - mobile Van der Waal bonded water
- Adsorbed water layer regrows between exposures
- Tritium migrates into freshly formed tritium-free water layer

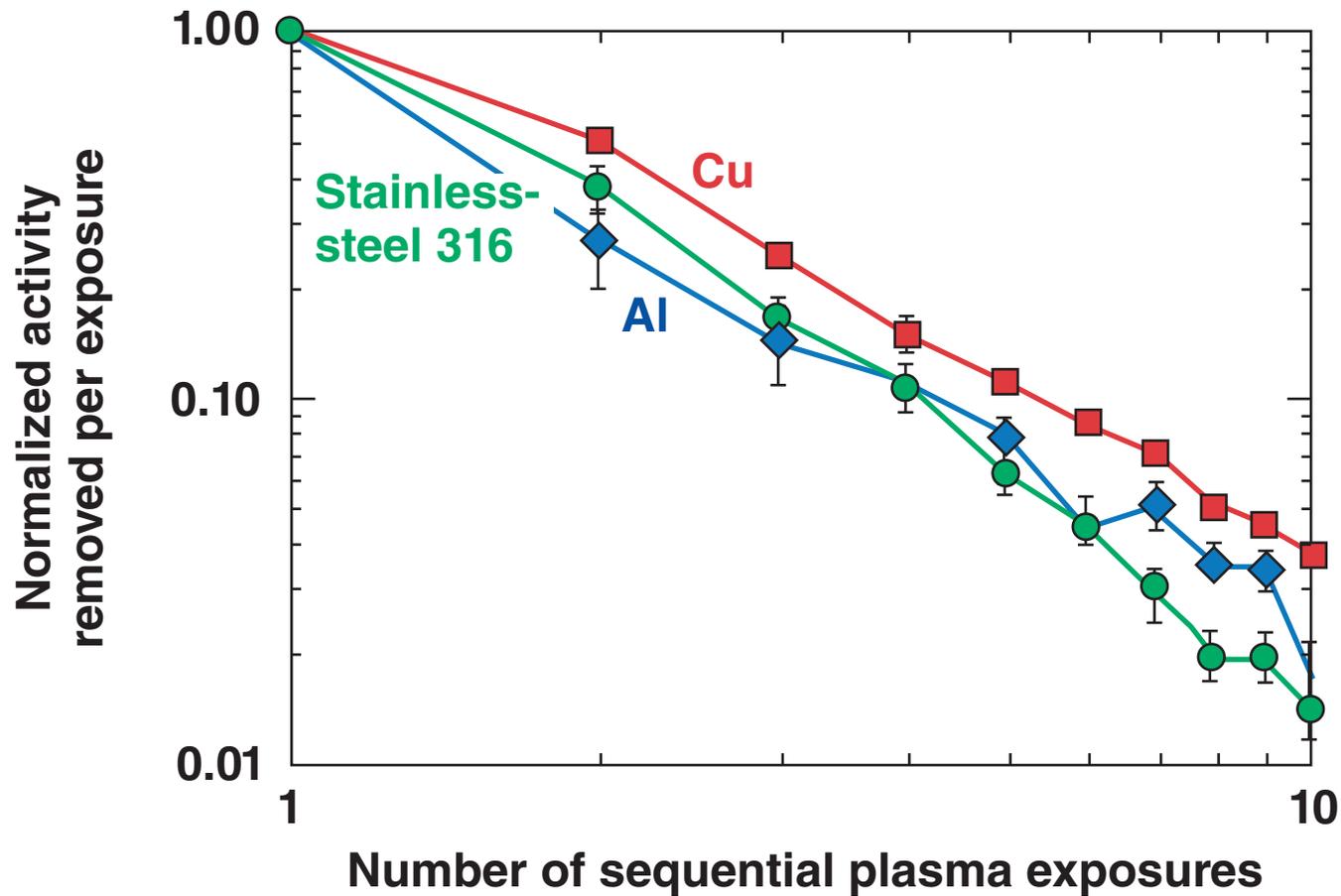
# Total removable surface activity increases with the number of monolayers of adsorbed water at a fixed relative humidity



### Water isotherm references

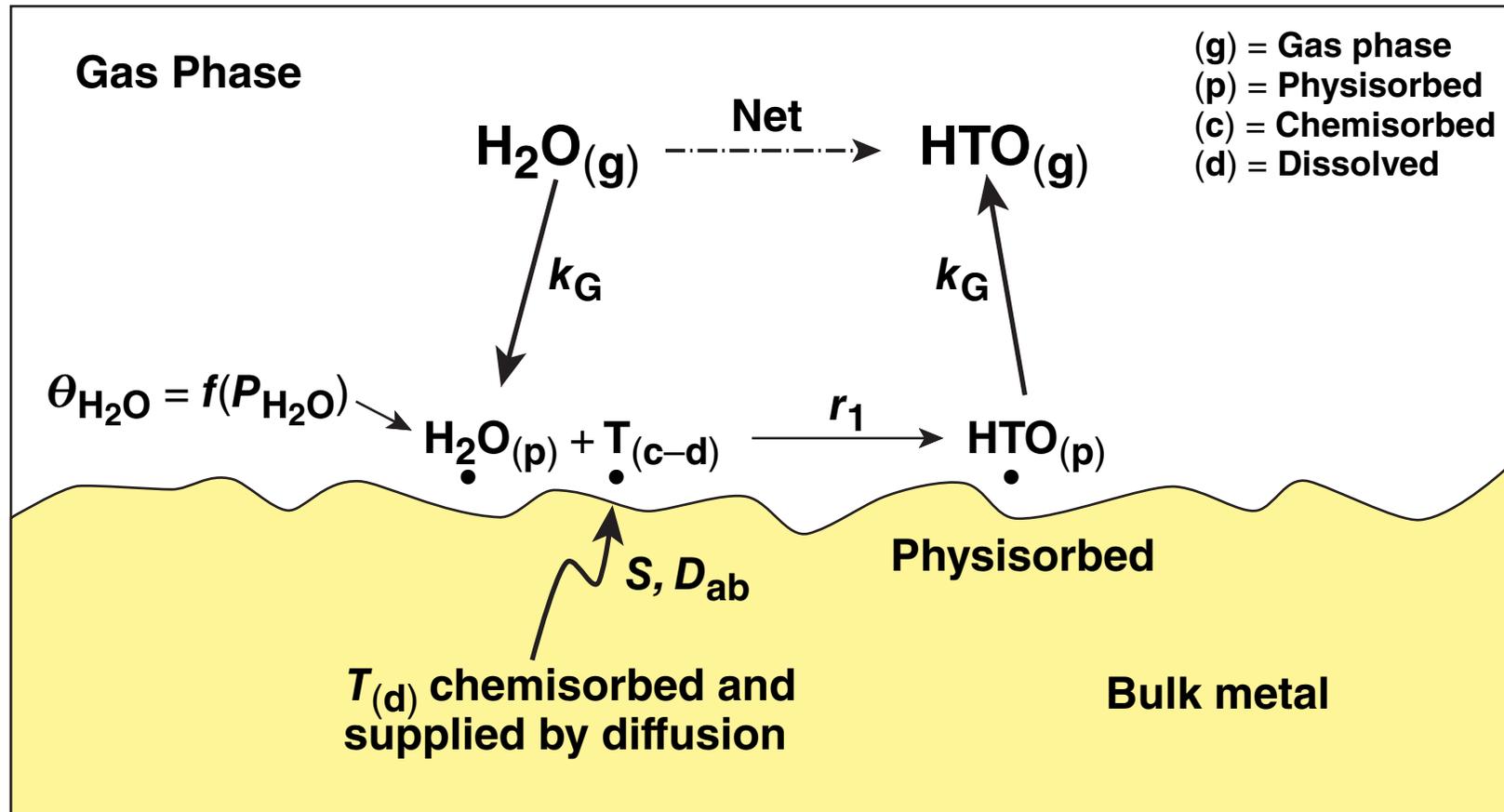
- Aluminum: H. A. Al-Abadleh and V. H. Grassian, *Langmuir* **19**, 341 (2003).
- Copper: S. P. Sharma, *J. Vac. Sci. Technol.* **16**, 1557 (1979).
- Stainless steel: T. Ohmi et al., *Rev. Sci. Instrum.* **64**, 2683 (1993).

# Activity removed from stainless steel, copper, and aluminum follows the same trend for all three metals

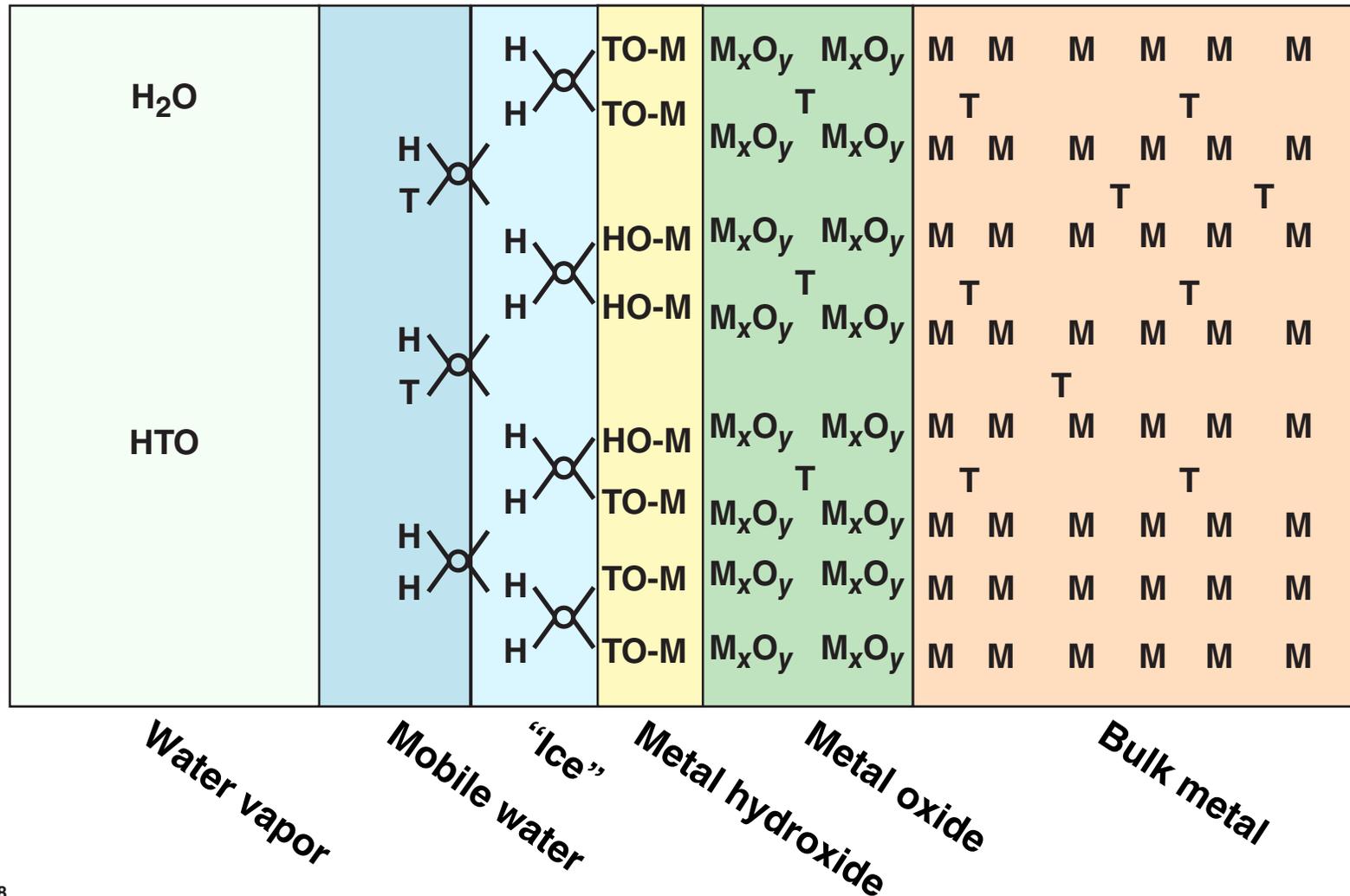


- Data were normalized to the initial amount removed

# The reactions among adsorbed species introduce a nonlinear behavior with respect to humidity



# Clean metal surfaces comprise layers of oxide, hydroxide, rigidly bound water, and mobile water in equilibrium with water vapor above the metal



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# Tritium migration to the surface is described by Fickian diffusion through the bulk driven by a rapid equilibrium across the surface bulk interface

Adsorbed water layer			Bulk metal	
H <sub>2</sub> O	HO		M	T
HTO	H <sub>2</sub> O	TO	M	T
H <sub>2</sub> O	HTO	TO	M	T
H <sub>2</sub> O	H <sub>2</sub> O	HO	M	T
HTO	HTO	TO	M	T

— Equilibrium

## Assumptions

- Surface and bulk concentrations are related through the equilibrium constant

– rapid equilibrium across the interface

$$C_{\text{bulk}} \leftrightarrow C_{\text{surface}}$$

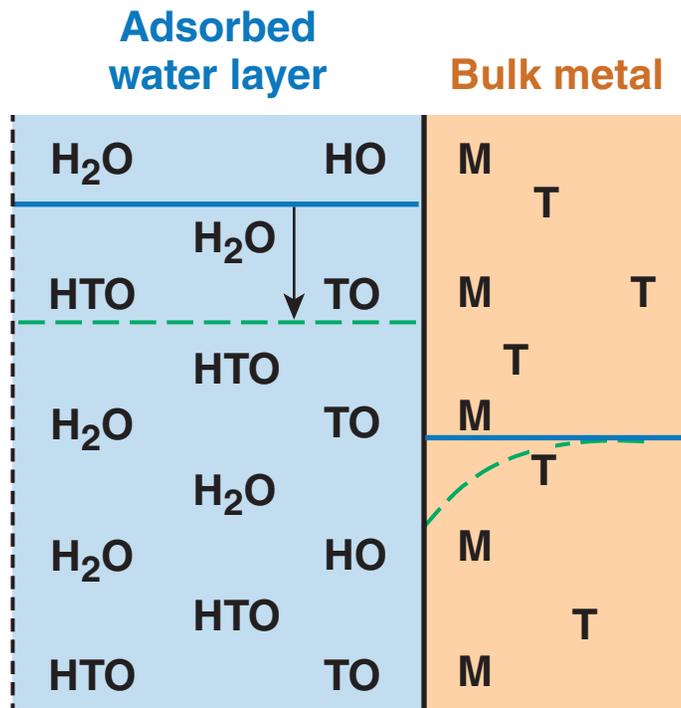
$$K_{\text{eq}} = \frac{C_{\text{surface}}^{\text{eq}}}{C_{\text{bulk}}^{\text{eq}}} = \frac{S_{\text{surface}}}{S_{\text{bulk}}}$$

- Rapid equilibrium in the adsorbed water layer

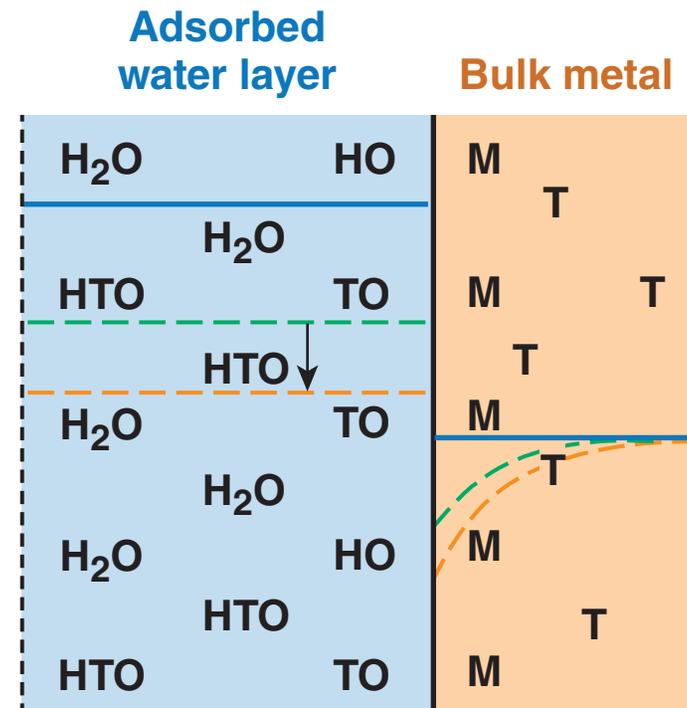
# A drop in the tritium concentration in the adsorbed water layer perturbs the equilibrium across the interface



- Tritons are drawn from the bulk to return to equilibrium across the interface

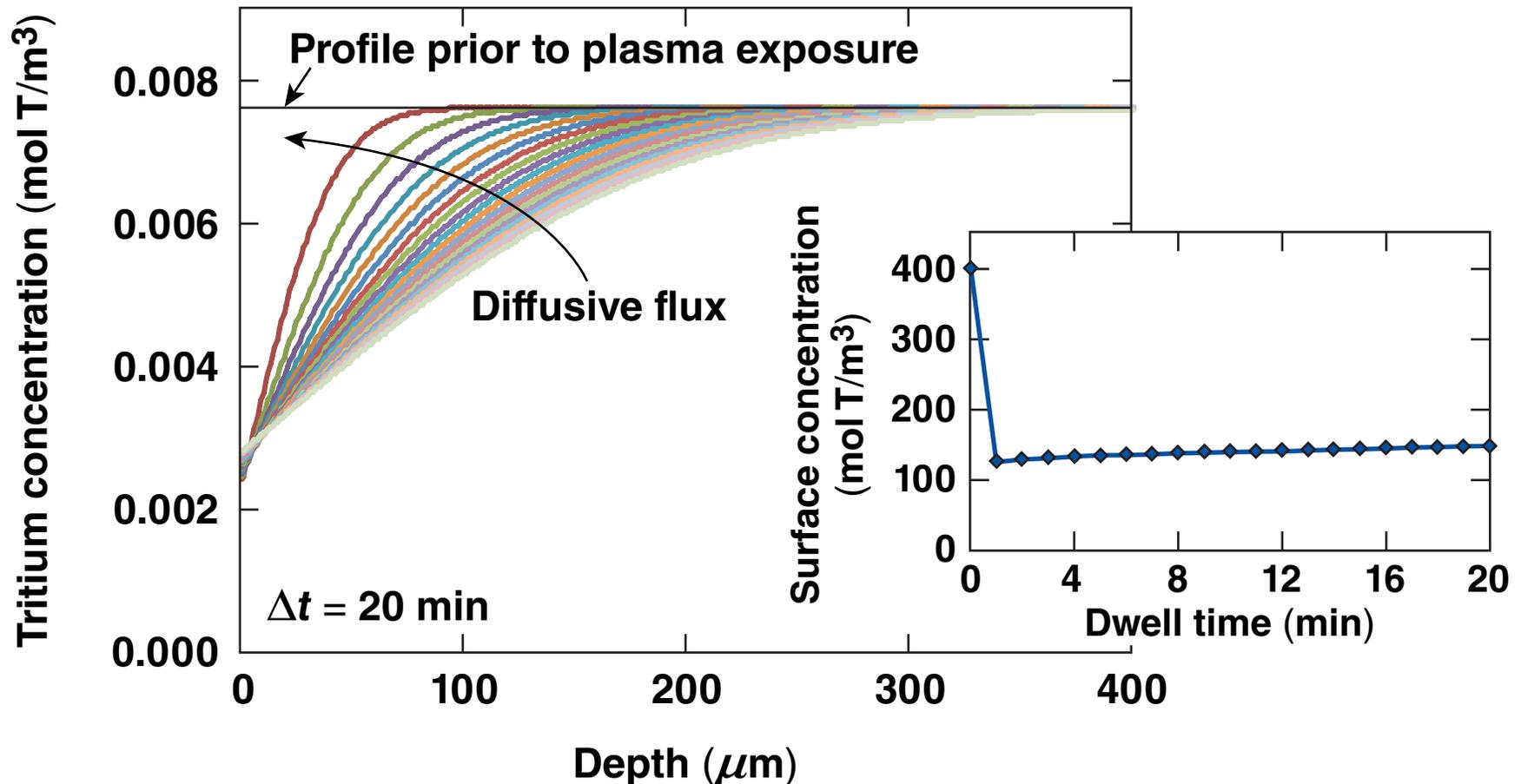


— Equilibrium  
 - - Response to "T"  
 empty water layer



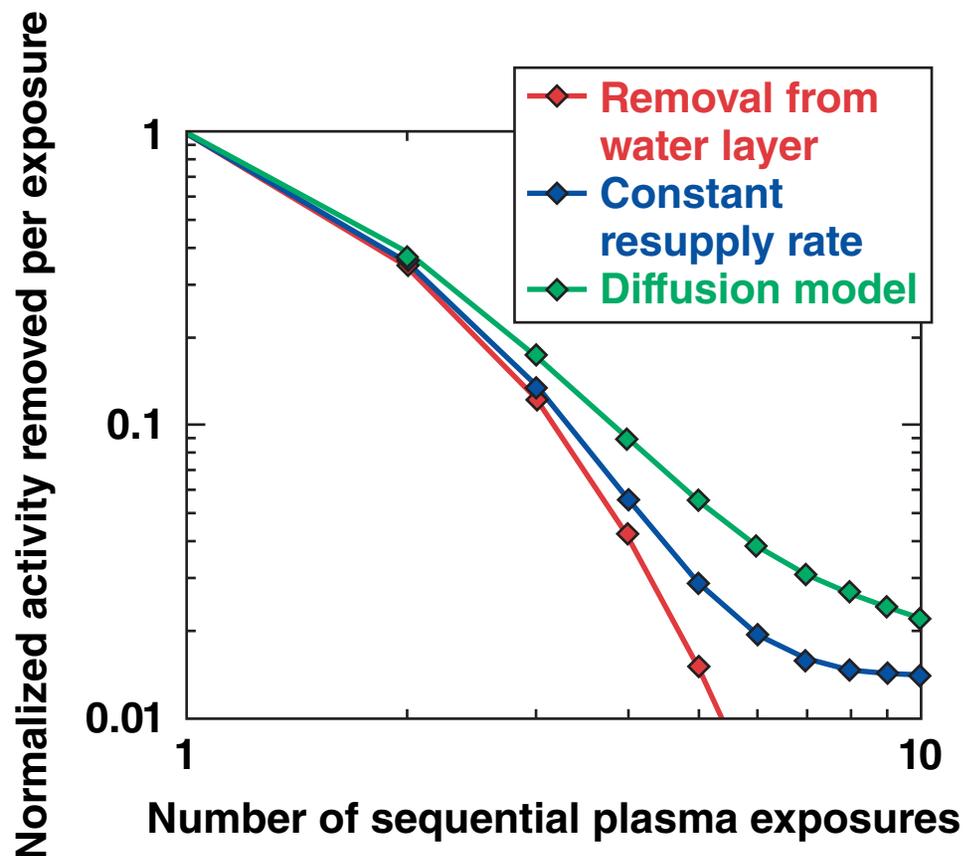
— Equilibrium  
 - - Response to "T"  
 empty water layer

# Tritium concentrations re-equilibrate after a plasma exposure removes surface activity



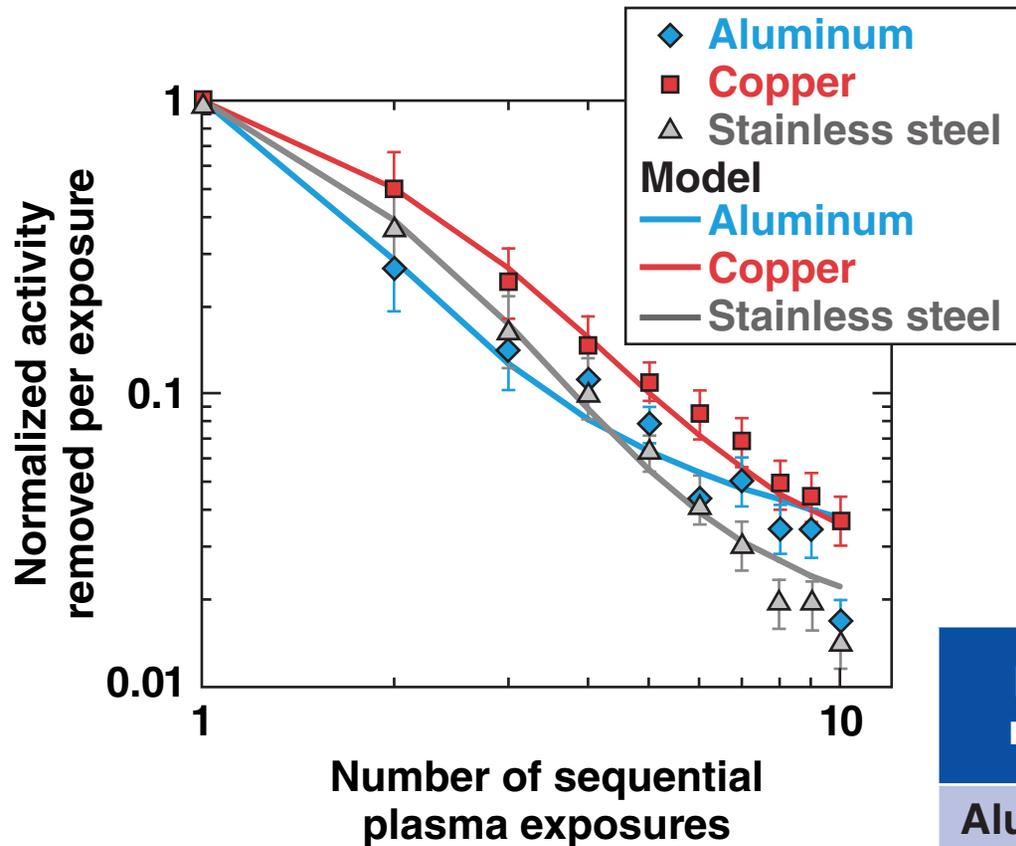
- Model utilizes a finite difference solution
  - concentration in each “cell” determined by flux balance

# Simulated activity removed suggests the first three exposures contain activity originated on the surface



- Each simulation assumes different mechanisms of regrowth
  - surface tritium alone
  - constant resupply rate
  - diffusion-limited resupply
- Simulations assume an overall efficiency = 0.65
- Trends begin to diverge at the third plasma exposure
  - sum of first three exposures is a good indication of initial surface activity

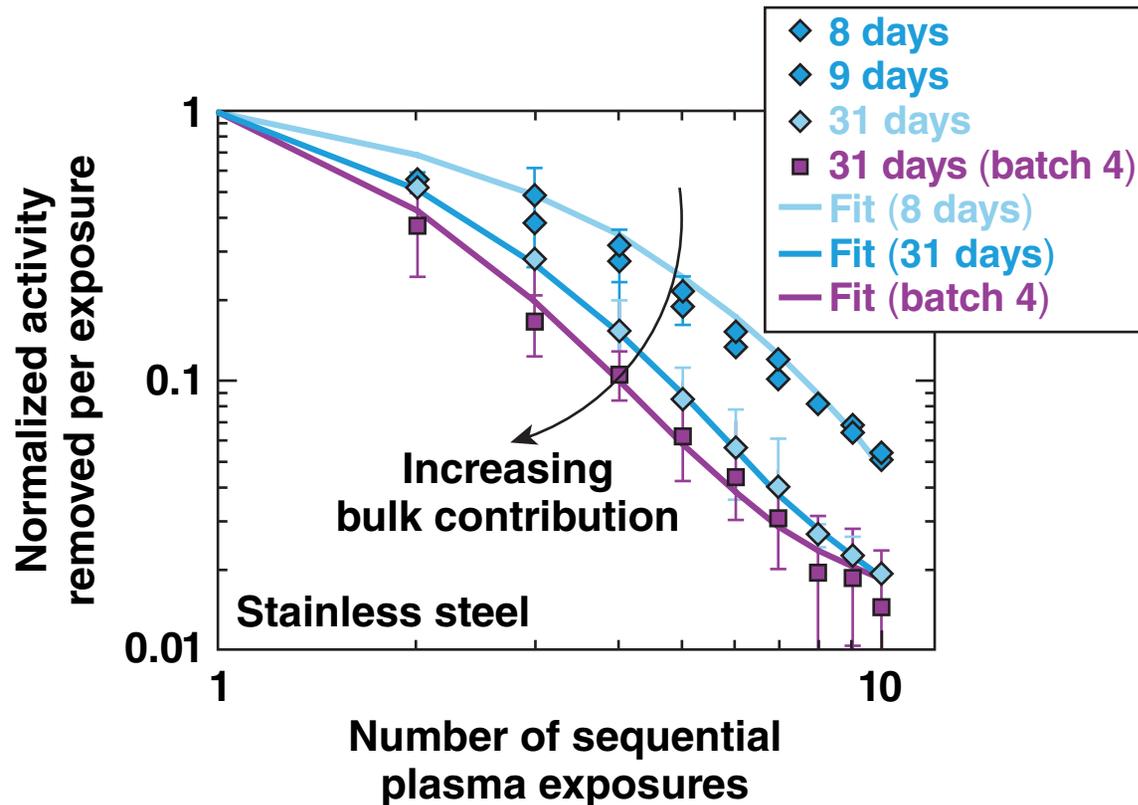
# Diffusion model can predict quantity of tritium removed during a series of plasma exposures



- Diffusion model fit to data by varying solubility ratio and overall efficiency
- Similar surface solubilities expected if tritium is primarily dissolved in adsorbed water

Base metal	Surface-layer solubility (kmol T/m <sup>3</sup> )	Overall efficiency
Aluminum	53±5	0.85
Copper	50±5	0.56
SS316	17±1	0.66

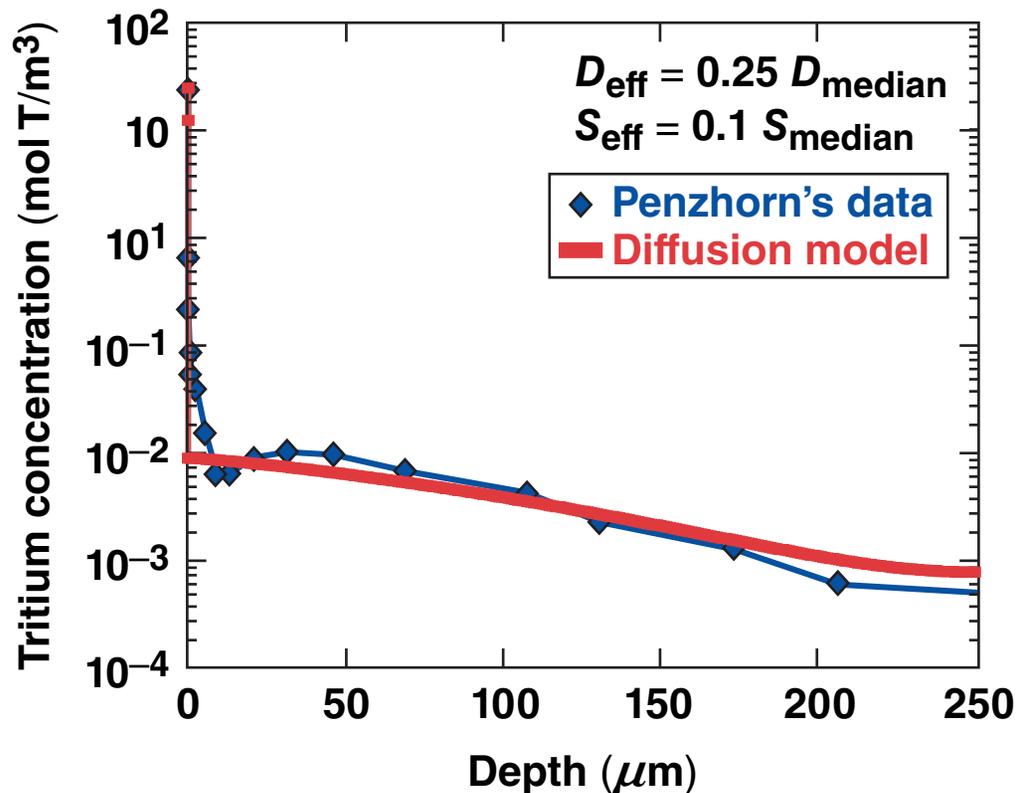
# The solubility ratio relaxes toward the equilibrium value



- Samples stored for shorter periods show an exponential trend
  - removal is predominantly from the surface
- Longer storage periods lower the surface fractions removed
  - migration into bulk depletes accessible tritium

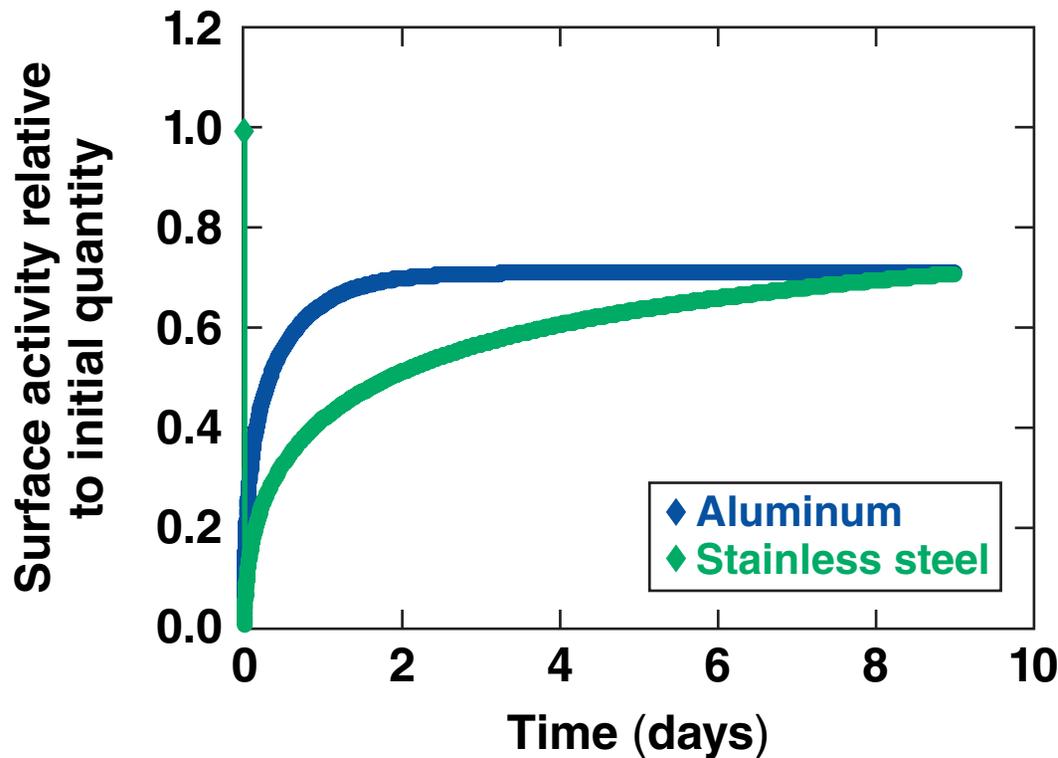
Storage time (days)	Solubility ratio	Overall efficiency
8	120,000	0.3
31	28,000	0.5
31 (batch 4)	20,000	0.6

# The diffusion model reproduces the previously measured concentration profiles by others



- Profiles measured by Penzhorn *et al.*\* using acid etching
- Median parameters were determined from the literature survey
  - effective parameters are still within the reported spread
- The model uses simplifying assumptions
  - no grain boundaries
  - no tritium loss to the air
  - does not reproduce the subtle details

# Bulk-metal diffusion determines the surface activity regrowth rate



- Initial concentration profiles are assumed to be in equilibrium in the metal and across the interface
- The surface activity was removed at  $t = 0$
- Concentration profiles were then allowed to recover from the perturbation
  - assume no tritium is lost from the sample

Surface concentrations regain ~70% of the initial activity after nine days.

# Summary/conclusions

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